THE SELECTIVE DISTINCTION OF DIETHYLISOPROPYLSILYL ETHER IN HYDROGENOLYSIS

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Summary: The diethylisopropylsilyl ether was distinguished from t-butyldimethysilyl, t-butyldiphenylsilyl and benzyl ethers with high selectivity in hydrogenolysis by use of Pd(OH)₂ as a catalyst.

Selection of the suitable protecting groups sometimes becomes key problem in the synthesis of complex natural products and silvl ethers are amongst the most useful protective groups $^{1)}$. Recently, we have reported the some advantages of the diethylisopropylsilyl (DEIPS) group which was a novel silyl group for hydroxyl function in organic synthesis^{2,3)}. In this communication, we wish to demonstrate that DEIPS ether was highly distinguished from tbutyldimethysilyl (TBS)4), t-butyldiphenylsilyl (TBDPS)5) and benzyl ethers in hydrogenolysis using Pd(OH)2 as a catalyst under neutral condition.

The benzyl ether was cleaved cleanly without deprotection of DEIPS group in hydrogenolysis in the presence of catalytic amounts of Pd(OH)₂6) in dioxane ^{3a)}(entries 1 in Table 1 and 2). In contrast to this fact, DEIPS group was removed smoothly with deprotection of benzyl ether in MeOH (entries 2 in Table 1 and 2). The change of the solvent made it possible to control the high selective distinction of DEIPS ether from benzyl ether.

Our next attention was turned to the selective deprotection of DEIPS group in the presence of TBDPS and TBS groups, which were widely used silyl protecting groups, in hydrogenolysis. The results summarized as entries 3 and 4 in Table 1 and 2 showed that DEIPS group was distinguished from these protecting groups with high selectivity and deprotected in MeOH in both primary and secondary positions. Although reaction times were not constant, the selectivities of the reactions were not significantly influenced by the reaction times.

These results indicated that DEIPS group was highly distinguished from TBS, TBDPS and benyl ethers under neutral condition.

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References and Notes:

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Ta	ble	1	7,8)

Entries	1	2	3	4
R ¹ O OR ²	R ¹ =Bn R ² =DEIPS	R ¹ =Bn R ² =DEIPS	R ¹ =TBDPS R ² =DEIPS	R ¹ =TBS R ² =DEIPS
Reaction Conditions Products	<i>dioxane</i> 26℃, 4.5h	<i>MeOH</i> 26°C, 6h	<i>MeOH</i> 26°C, 1h	MeOH 40°C, 1h
R ¹ 0 OR ²	0%	0%	0%	0%
R ¹ O OH	0%	0%	99%	71%
HO (Type B)	98%	0%	0%	12%
но	0%	93%	0%	15%
Table 2. ^{7,8)}				
Entries	1	2	3	4
OR ²	R ¹ =Bn R ² =DEIPS	R ¹ =Bn R ² =DEIPS	R ¹ =TBDPS R ² =DEIPS	R ¹ =TBS R ² =DEIPS
Reaction Conditions Products	dioxane 26°C, 3h	<i>MeOH</i> 26°C, 3h	MeOH 26°C, 1h	<i>MeOH</i> 26℃, 1h
OR ²	0%	0%	0%	0.5%
R ¹ O (Type A) OR ²	0%	0%	98%	75%
HO (Type B)	96%	0%	0%	3%
HO OH	0%	91%	0%	13%

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All new products were purified by silica gel column chromatography and were fully characterized by

spectroscopic means.

Isolated yield after column chromatography on slica gel. The ratio of type A and type B was determined 8) by ¹H-NMR analysis.